					Docket Number (Optional) 01-9665-06		pplication Number. 10/7	34,073	
	INFO	PALSTION DISCLOSURE (Use several sheets if necessor	E CITATION		Applicant(s)  Degner et al.			<del></del>	, , , , , , , , , , , , , , , , , , ,
	MAY			Filing Date Dec. 12, 2003		I .	Group Art Unit Unknown		
		2004	<u></u>	U.S. PAT	ENT DOCUMENTS		- Citi	KIIOWII	
*EXAMINER	REF	ADEMARKS INT NUMBER	DATE	NAME		CLASS	SUBCLASS	FILING	
INITIAL	A	4,386,979	5/31/83	Pierce 6	et al.	204	298	IF APPRO	PRIATE
	В	See Below							
	С	4,564,435	1/14/86	Wicker	sham	204	298		
	D	4,931,135	6/5/90	Horiuc	hi et al.	156	643		<del></del> :
	E	4,820,371	4/11/89	A. D. Rose  Loewenstein		156	345		
.,	F	4,904,621	2/27/90			437	225		
	G	4,367,114	1/4/83	Steinberg et al.		156	643		
	н	4,297,162 10/27/81		Mundt et al.		156	643		·
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	к	4,544,091	10/1/85	Hidler et al.		228	124		
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						F	RECÉIVE	ΞD	
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	<b>1</b>		-1	OTHER	DOCUMENTS (Includin	ng Author, Title, L	Date, Pertinent Pa	ges, Etc.)	
	McGuire, SEMICONDUCTOR MATERIAL AND PROCESS TECHNOLOGY HANDBOOK, FOR VERY LAR INTEGRATION (VLSI) AND ULTRA LARGE SCALE INTEGRATION (ULSI), Copyright 1988, Noyes Publica Chapter 5, Particularly Pages 272-279, Fig. 51aiii								E SCALE
EXAMINE	R	•		DATE CONSIDERED					
		al if citation considered, whether clude copy of this form with next			I nce with MPEP Section 609	; Draw line throu	gh citation if not	in conform	ance and